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10/588,098	12/18/2006	W. Dennis Slafer	59380-050 (MCMK-004)	4357	
	7590 10/15/200 `WILL & EMERY LL		EXAM	IINER	
28 STATE STR	REET		RIVERA,	JOSHEL	
BOSTON, MA	02109-1775		ART UNIT	UNIT PAPER NUMBER	
			1791		
			NOTIFICATION DATE	DELIVERY MODE	
			10/15/2009	ELECTRONIC	

# Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

BostonIPDocket@mwe.com

		Application No.	Applicant(s)		
Office Action Summary		10/588,098 SLAFER, W. DENNIS			
		Examiner	Art Unit		
		JOSHEL RIVERA	1791		
5 . 16	The MAILING DATE of this communication app		the correspondence address		
Period fo	• •	VIO OET TO EVEIDE A MON	ITHES OF THE THE TAKES		
WHI0 - Exte after - If No - Failt Any	HORTENED STATUTORY PERIOD FOR REPLICHEVER IS LONGER, FROM THE MAILING Densions of time may be available under the provisions of 37 CFR 1.1 r SIX (6) MONTHS from the mailing date of this communication. O period for reply is specified above, the maximum statutory period ure to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1,704(b).	ATE OF THIS COMMUNICA 136(a). In no event, however, may a reply will apply and will expire SIX (6) MONTHS a, cause the application to become ABANI	TION. y be timely filed S from the mailing date of this communication. DONED (35 U.S.C. § 133).		
Status					
1)🖂	Responsive to communication(s) filed on 26 Ju	<u>une 2009</u> .			
2a)⊠	This action is <b>FINAL</b> . 2b) ☐ This				
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is				
	closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 1	1, 453 O.G. 213.		
Disposit	tion of Claims				
4)🛛	Claim(s) <u>1-20</u> is/are pending in the application	l.			
	4a) Of the above claim(s) is/are withdra	wn from consideration.			
5)	Claim(s) is/are allowed.				
	Claim(s) <u>1-20</u> is/are rejected.				
	Claim(s) <u>1</u> is/are objected to.				
8)	Claim(s) are subject to restriction and/c	or election requirement.			
Applicat	tion Papers				
9)	The specification is objected to by the Examine	er.			
10)🛛	The drawing(s) filed on 28 July 2006 is/are: a)	⊠ accepted or b)□ objected	d to by the Examiner.		
	Applicant may not request that any objection to the	drawing(s) be held in abeyance.	. See 37 CFR 1.85(a).		
_	Replacement drawing sheet(s) including the correct				
11)	The oath or declaration is objected to by the Ex	xaminer. Note the attached O	office Action or form PTO-152.		
Priority	under 35 U.S.C. § 119				
12)🔯	Acknowledgment is made of a claim for foreign	n priority under 35 U.S.C. § 1	19(a)-(d) or (f).		
·	)⊠ All b)□ Some * c)□ None of:		,,,,,		
	1. Certified copies of the priority document	ts have been received.			
	2. Certified copies of the priority document	ts have been received in App	lication No		
	3. Copies of the certified copies of the prior	rity documents have been re	ceived in this National Stage		
	application from the International Burea	· · · · · · · · · · · · · · · · · · ·			
* (	See the attached detailed Office action for a list	of the certified copies not red	ceived.		
Attachmer	nt(s)				
	ce of References Cited (PTO-892)		nmary (PTO-413)		
3) Infor	ce of Draftsperson's Patent Drawing Review (PTO-948) rmation Disclosure Statement(s) (PTO/SB/08) er No(s)/Mail Date	<b>—</b> ' ' '	Mail Date rmal Patent Application		

Art Unit: 1791

#### **DETAILED ACTION**

### Claim Objections

- 1. Claim 1 is objected to because of the following informalities: the claim recites "...a substrate of about 4  $\mu$  to about 1000  $\mu$ ". There is no unit known as " $\mu$ ". The claim will be interpret as "...a substrate of about 4  $\mu$ m to about 1000  $\mu$ m" or "...a substrate of about 4 microns to about 1000 microns" since 1  $\mu$ m is 1 micron.
- 2. Additionally claim 1 reads that the optical data storage includes "an elongated linear polymer layer and a substrate of about 4  $\mu$ m to about 1000  $\mu$ m". Page 12 paragraph 40 of the Specification reads that "the optical data storage tape 10 is characterized by a thin (in the approximate range of 4 microns to 1000 microns), elongated tape-like substrate..." Based on this description it is clear that the claim should read "an elongated linear polymer layer with a thickness of about 4  $\mu$ m to about 1000  $\mu$ m". Examiner will interpret the claim as stated above. Appropriate correction is required. Use of term "like" is improper, since it does not specifically define the shape of the substrate.

Art Unit: 1791

# Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

- 3. Claims 1, 2, 4, 5, 9, 10 and 20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tamura et al (US Patent 5,096,401).
- 4. With respect to claim 1, Tamura teaches of an apparatus for producing substrate sheet for optical recording media (Abstract), which includes en elongated linear polymer layer that has a thickness of about 0.3 to about 1.5 mm (300 μm to 1500 μm) (column 6 lines 16 18), the apparatus comprising a drum mounted for rotation about a rotation axis (Figure 1 item 3), with a surface with predetermined pattern (column 5 lines 66 67) and an ultraviolet lamp to cure the elongated linear polymer layer prior being peeled from the drum (column 6 lines 23 27). Tamura states that the drum can be prepared by directly engraving patterns on a mirror-finished roll (column 5 lines 58 59). Tamura fails to explicitly disclose that the drum is seamless with a seamless surface.
- 5. It would have been obvious to one of ordinary skills in the art at the time of the invention to use a seamless drum in Tamura's apparatus. The rationale being that, since the preformatted patterns are directly engraved on the roll the presence of seams

Art Unit: 1791

would affect the pattern which would affect the information present in the patterns, as stated by Tamura (column 5 lines 66 - 67).

- 6. With regards to claim 2, the teachings of Tamura are presented above.

  Additionally Tamura teaches a dispenser for dispensing a liquid between the drum and the elongated linear polymer (Figure 1 item13 is the dispenser and item 2 is the liquid).
- 7. With regards to claim 4, the teachings of Tamura are presented above. Additionally Tamura teaches that the liquid in the dispenser is a ultraviolet-curable resin and the embossments have been transferred to this layer (column 5 lines 1 8).
- 8. With regards to claim 5, the teachings of Tamura are presented above.

  Additionally Tamura illustrates the use of backing rollers to press the elongated linear polymer layer against the drum (Figure 1 items 12 and 14).
- 9. With regards to claim 9, the teachings of Tamura are presented above. Additionally Tamura states that the patterns that are made on the substrate are grooves (column 5 lines 66 68, column 6 lines 1 3), where intrinsically grooves would have ridges and bosses.
- 10. With regards to claim 10, the teachings of Tamura are presented above.
  Additionally Tamura states that the preformatted patterns corresponds with
  preformatting information that are tracking grooves and encoded information in the form

of readable marks (column 5 lines 66 - 68, column 6 lines 1 - 2), the encoded information would intrinsically include header information, servo and error correction information, pre-recorded digital information and pre-recorded analog information.

Page 5

- 11. With regards to claim 20, the teachings of Tamura are presented above. Additionally Tamura teaches using a primer in order to improve the adhesion between the polymer layer and the resin layer (column 5 lines 48 51), where the resin layer is embossed with recordable information at the same time it's embedded to the polymer layer (Figure 1, column 5 lines 1 8, lines 66 68).
- 12. Claims 3, 6 and 7 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tamura et al (US Patent 5,096,401) in view of Norden (WO 97/14142).
- 13. With regards to claim 3, the teachings of Tamura are presented above. Tamura fails to explicitly disclose using a chemical to soften the surface of the polymer layer.
- 14. Norden teaches an embodiment where he uses a chemical to soften the polymer layer prior embossing and then using heat in order to remove the softening chemical after embossing (column 5 lines 25 31).
- 15. It would have been obvious to one of ordinary skills in the art at the time of the invention to use a softening chemical on the surface of the polymer layer, as suggested by Norden, in Tamura's apparatus. The rationale being that in order to create an impression on a hard plastic surface would require large amount of force and energy, where using a chemical to soften the surface prior embossing saves money and time.

Application/Control Number: 10/588,098

Art Unit: 1791

16. With regards to claim 6 and 7, the teachings of Tamura and Norden are presented above. Additionally Norden teaches using Vacuum Vapor Deposition to coat a reflection layer on top of the embossed surface (column 9 lines 29 – 31).

Page 6

- 17. It would have been obvious to one of ordinary skills in the art at the time of the invention to use a Norden's Vacuum Vapor Deposition chamber to apply an optical recording layer on the pattern made by Tamura's apparatus. The rationale being that, as stated by Norden, the use of this layer ensures that, when the registration side of the medium is scanned with a focused light beam, enough light intensity is reflected to yield an acceptable output signal level (column 6 lines 18 20). The rationale to use a vacuum chamber would be to eliminate possible contamination by the environment.
- 18. Claim 8 is rejected under 35 U.S.C. 103(a) as being unpatentable over Tamura et al (US Patent 5,096,401) in view of Norden (WO 97/14142) as applied to claim 6 and 7 above, and further in view of Takakuwa et al (US Patent 6,162,519).
- 19. With regards to claim 8, the teachings of Tamura and Norden are presented above. Tamura and Norden fail to explicitly disclose the use of an optical head array adapted to write recording marks in the optical recording layer over the pattern of optically readable embossments.
- 20. Takakuwa teaches a method to write recording marks using a laser cutting machine with pattern based on desired data (column 13 lines 12 14).

Art Unit: 1791

21. It would have been obvious to one of ordinary skills in the art at the time of the invention to use Takakuwa's laser cutting machine to write recording markings in Tamura and Norden's apparatus. The rationale to do so would have been that by using a laser cutting machine a more precise and detailed pattern can be formed without affecting the prior embossed pattern by using another press or pressing a blade on the surface of the polymer.

- 22. Claims 11 17 and 19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Norden (WO 97/14142) as evidenced by Rosen et al (US Patent 5,627,817).
- 23. With regards to claim 11, Norden teaches a method of first chemically softening the surface of a polymer layer (column 5 lines 25 29), embossing the registration layer to form a pattern of low and high surface regions representing a collection of binary data (column 3 lines 23 24) and hardening prior being removed from the drum (column 10 lines 27 29). Norden fails to explicitly disclose that the drum is seamless having protrusions on a seamless surface.
- 24. It would have been obvious to one of ordinary skills in the art at the time of the invention to use a seamless drum in Norden's method. The rationale being that the presence of seams would affect the pattern which would affect the information present in the patterns.

Application/Control Number: 10/588,098

Art Unit: 1791

25. With regards to claim 12, the teachings of Norden are presented above.

Additionally Norden teaches an embodiment where he uses a chemical to soften the surface of the polymer layer prior embossment (column 5 lines 25 – 29).

Page 8

- 26. With regards to claim 13, the teachings of Norden are presented above.

  Additionally Norden teaches an embodiment of using a ultraviolet-curable material where the embossing takes place and then is cured after embossing (column 5 lines 7 16).
- 27. With regards to claim 14, the teachings of Norden are presented above. Additionally Norden teaches applying a metallic reflection layer to the embossed surface of the registration layer, where binary data are represented by localized level variations, where the reflection layer ensures that, when the registration side of the medium is scanned with a focused light beam, enough light intensity is reflected to yield an acceptable output signal level (column 6 lines 13 20, column 7 lines 19 20), which would intrinsically classify this layer as an optical recording layer.
- 28. With regards to claim 15, the teachings of Norden are presented above. Additionally Norden teaches that the reflection layer has localized level variations (column 7 lines 19 20), which can be achieved by endowing the registration layer with a pattern of pits or bumps what can be represent "0" and "1" (column 7 lines 31 34, column 8 lines 1 6).

Art Unit: 1791

- 29. With regards to claim 16, the teachings of Norden are presented above. Additionally Norden teaches using a dielectric layer (column 7 lines 9 10), a reflection layer (column 7 lines 27 28) and the use of squarylium dye (column 7 lines 1 4) that, as stated by Rosen, its functionally equivalent to a phase change layer (column 1 lines 21 40).
- 30. With regards to claim 17, the teachings of Norden are presented above. Additionally Norden teaches that the embossed forms are usually pits of constant width but variable length (column 4 lines 14 15, lines 18 23), which would intrinsically comprise of lands and grooves, and these marks are in an helical path (column 4 lines 18 23) which would be wobbled.
- 31. With regards to claim 19, the teachings of Norden are presented above. Additionally Norden teaches that a registration layer is provided on the substrate and that the embossing is done under pressure (column 3 lines 21 24). Intrinsically if the embossing is done under pressure on the registration layer, the layer would be embedded into the polymer layer as the embossments are created.
- 32. Claims 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Norden (WO 97/14142) in view of Tamura et al (US Patent 5,096,401).

Art Unit: 1791

33. With regards to claim 18, the teachings of Norden are presented above. Norden teaches embossing the registration layer (column 4 lines 18 - 23) to represent a collection of binary data (column 3 lines 22 - 24). Norden fails to explicitly disclose the information provided in these embossments.

34. Tamura states that the preformatted patterns corresponds with preformatting information that are tracking grooves and encoded information in the form of readable marks (column 5 lines 66 – 68, column 6 lines 1 – 2), the encoded information would intrinsically include header information, servo and error correction information, pre-recorded digital information and pre-recorded analog information. It would have been obvious to one of ordinary skills in the art at the time of the invention that the information in Taruma's embossments would be the same as in Norden. The rationale being that both Taruma and Norden are manufacturing optical disks in the same field of endeavor, therefore both must contain the same information in the embossments.

# Response to Arguments

35. Applicant's arguments, see page 5, filed June 26, 2009, with respect to the rejection(s) of claim(s) 1-5, 7, 9, 10 and 20 under 102 (b) have been fully considered and are persuasive. Therefore, the rejection has been withdrawn. However, upon further consideration, a new ground(s) of rejection is made in view of Tamura et al (US Patent 5,096,401). As applicant stated Okubo fails to teach that the substrate has a thickness of 4  $\mu$ m to 1000  $\mu$ m and only provided a substrate with a thickness of 1200

Art Unit: 1791

μm (1.2 mm). Upon further review Taruma teaches an apparatus similar to the one described by Okubo for substrates with thickness of 300 μm to 1500 μm (0.3 mm to 1.5 mm), which falls into range of 4 m to 1000 μm described by the applicant. Another difference that Taruma has in contrast with Okubo is that also has a solid roll with mirror finish and patterns engraved directly to the roll, as explained in the rejection above.

- 36. With respect to applicant's arguments for claims 11 14 and 16, based on the amendments made to claim 11 the rejection has been withdrawn and a new grounds of rejections have been made. Nevertheless there is no claim limitation regarding that the product made by the applicant's method has to be a recordable or erasable optic tape.
- 37. Applicant's arguments with respect to claims 6, 8, 15, 17 19 have been considered but are moot in view of the new ground(s) of rejection.
- 38. Additionally, with respect to claim 8, there is no indication in the Specification that a polyolefin substrate cannot be used. Therefore the Examiner does not suggest adding the amendment of "a non-polyolefin" material in claim 1 as suggested by the Applicant.

#### Conclusion

39. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP

§ 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to JOSHEL RIVERA whose telephone number is (571) 270-7655. The examiner can normally be reached on Monday - Thursday 7:30am - 6:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Katarzyna Wyrozebski can be reached on (571) 272-1127. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Art Unit: 1791

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/J. R./ Examiner, Art Unit 1791

/KAT WYROZEBSKI/ Supervisory Patent Examiner, Art Unit 1791